Impact ionization and carrier multiplication in graphene

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We develop a model for carrier generation by impact ionization in graphene, which shows that this effect is non-negligible because of the vanishing energy gap, even for carrier transport in moderate electric fields. Our theory is applied to graphene field effect transistors for which we parameterize the carrier generation rate obtained previously with the Boltzmann formalism [A. Girdhar and J. Leburton, Appl. Phys. Lett. 99, 229903 (2011)] to include it in a self-consistent scheme and compute the transistor I-V characteristics. Our model shows that the drain current exhibits an “up-kick” at high drain biases, which is consistent with recent experimental data. We also show that carrier generation affects the electric field distribution along the transistor channel, which in turn reduces the carrier velocity. © 2012 American Institute of Physics. [http://dx.doi.org/10.1063/1.4761995]

I. INTRODUCTION

In recent years, graphene has emerged as a new electronic material with unusual physical properties, due to its two-dimensional (2D) nature and its band structure, where the carrier energy is linear in momentum and the gap separating conduction and valence bands is reduced to the single Dirac point.1 For this reason, a large amount of work has been devoted to explore new physical effects and exploiting them in various technological applications.2–7 In this context, graphene’s 2D nature and high carrier velocity are well suited for high speed and high performance electronics, for which the interaction between charge carriers and static and dynamic lattice defects has been studied well.8 By contrast, less attention has been paid to interband interaction amongst carriers.9,10 In conventional semiconductors, it is well known that this kind of inter-carrier interaction is characterized by an energy threshold of the order of the energy gap, which restricts the energy exchange amongst carriers to the most energetic ones and thus becomes significant in high electric fields.11 In gapless graphene such a condition is not fulfilled.

Very recently, electron-hole generation rates caused by interband carrier-carrier interaction in the presence of electric fields have been obtained, which confirms the absence of energy threshold for impact ionization.12 Moreover, it was shown that the generation rate is quasi-quadratic in the electric field at constant carrier temperature and strongly decreases with the carrier concentration as it reduces the density of final scattering states for both particles. Therefore, it becomes evident that any analysis of the transport characteristics of graphene without the consideration of impact ionization and its consequence on the carrier concentration is incomplete.

In this paper, we provide a physical model that takes into account impact ionization in non-linear transport in graphene and graphene-based devices, specifically field-effect transistors that are mostly utilized to extract transport parameters as a function of carrier concentrations.13

II. IMPACT IONIZATION-LIMITED TRANSPORT MODEL

Let us consider a graphene sheet placed in an electric field $F$ in the $x$-direction. At steady state, and in the presence of impact ionization, both electron and hole current densities $J_n$ and $J_p$ satisfy the 1D continuity equations

$$\frac{dJ_n}{dx} + eG(x) = 0$$

(1a)

and

$$\frac{dJ_p}{dx} - eG(x) = 0,$$

(1b)

where $G(x)$ is the net electron-hole pair (EHP) generation rate. Combining these two equations yields

$$\frac{d(J_p + J_n)}{dx} = 0$$

(2a)

and

$$\frac{d(J_p - J_n)}{dx} - 2eG(x) = 0,$$

(2b)

where Eq. (2a) expresses the total current conservation and $2 G(x) = U$ is the particle generation rate given by12

$$U = \frac{8}{\mathcal{A}} \sum_{\vec{k}_1, \vec{k}_2, \vec{k}_1', \vec{k}_2'} S(\vec{k}_1, \vec{k}_1'; \vec{k}_2, \vec{k}_2') \left\{ \frac{\left[f(k_1')\right]}{f(k_2')} \left[1 - f(k_1)\right] \left[1 - f(k_2)\right] \right\} \left\{ \frac{\left[1 - f(k_1)\right]}{f(k_1')} \left[1 - f(k_2')\right] \left[1 - f(k_2')\right] \right\} \delta_{k_1 + k_2,k_1'+k_2'},$$

(3)
where
\[
S(k_1, k_1'; k_2, k_2') = (2\pi/\hbar)|M|^2 \delta(E_1 + E_2 - E_1' - E_2').
\] (4)

Here, \(M = e^2/(2\kappa_{\text{eff}}\kappa_0q\varepsilon(q))\) where \(\kappa_{\text{eff}}\) is the effective dielectric constant of a single layer graphene on an insulating substrate and \(\varepsilon(q)\) is the static screening dielectric function of the \(q = k_1 - k_1'\) wave vector. The factor 8 accounts for spin and valley degeneracies as well as two distinct particles, electron and hole. \(k_1'\) and \(k_2'\) are the initial wave vectors of electrons in the conduction (C) band and valence (V) band, respectively, and \(k_1\) and \(k_2\) are the final wave vectors in the conduction band (CVCC process). A similar equation also describes the VCVV process. \(f(k)\) is the carrier distribution function assumed to be a displaced Fermi-like distribution with an electronic temperature \(T_e\), and \(A\) is the sample area. The reduction of the 8-ple summation in Eq. (3) to a quadruple integral to obtain numerically the generation rate is demonstrated in Appendix A.

FIG. 1. Current densities as a function of applied fields for temperature 300–1200 K at various carrier concentrations. Squares are values obtained from Ref. 12 and the solid lines are the data best fit. The carrier concentrations for each electronic temperature are \(10^{12}\) cm\(^{-2}\), \(2 \times 10^{12}\) cm\(^{-2}\), \(5 \times 10^{12}\) cm\(^{-2}\), \(10^{13}\) cm\(^{-2}\) (from top to down).

The generation rate obtained numerically from Eq. (A13) is cumbersome for the integration of Eqs. (2). For this reason, we propose the following expression
\[
U = gF^2\exp[\frac{-n}{n_0}],
\] (5)

where \(g\), \(n_0\), and \(x = 1.66 - 1.75\) are fitted from Fig. 1 data. The \(x\)-value is slightly smaller than 2 (Fig. 2(a)), because \(U\) deviates from the strictly quadratic dependence on the electric field at high fields\(^{12}\) and slightly increases with carrier concentration. For the sake of simplicity, we will use \(x = 1.7\). Fig. 2(b) shows the exponential variation of \(U\) with carrier concentration for different temperatures, where the \(n_0\)-parameter is a linear function of the electronic temperature (Fig. 2(c)). It was also found that a variation \(g \propto T_e^{3/2}\) on the electronic temperature constitutes a good approximation. Finally, one can relate the electronic temperature \(T_e\) on the electric fields by the usual quadratic expression\(^{15}\)
\[
T_e = T_L \left[1 + \left(\frac{E}{F_{\text{CT}}}ight)^2\right],
\] (6)

where \(T_L\) is the lattice temperature and \(F_{\text{CT}}\) is a critical field for the onset of hot carrier effects, which depends on various scattering mechanisms.

III. IMPACT IONIZATION IN GRAPHENE FIELD EFFECT TRANSISTOR (FET)

In order to compare our carrier generation model with available experimental data on high field transport, we consider the standard configuration of a graphene FET shown in...
Fig. 3 for n-channel. In the charge-control model, one can write quite generally,

\[ Q_+ - Q_- = \pm C_{ox}(V_{GT} - V(x)), \]  

(7)

for the ambipolar nature of the graphene channel charge, where \( Q_+ \) and \( Q_- \) are the hole and the electron charges, respectively, \( C_{ox} \) is the oxide capacitance (here, we neglect the quantum capacitance \( C_Q \sim C_{ox} \)), and \( V_{GT} = V_G - V_T \), where \( V_G \) is the gate bias and \( V_T \) is the gate voltage at minimum conductance. The \( \pm \) sign is for electron (+) and hole (−) channels, so that \( V_{GT} \) is positive and negative, respectively, and \( V(x) \) is the potential drop along the channel (source at \( x = 0 \)). We define the hole/electron current as \( I_{p,n} = \pm Q_+ - Wv_{p,n}(F) \), where \( W \) is the graphene channel width and \( v_{p,n}(F) \) is the carrier velocity given by

\[ v(F) = \pm \frac{\mu_0 F}{1 + F/F_C}. \]

(8)

where the \( \pm \) sign is for holes (+) and electrons (−), respectively, and \( F \) is the electric field. The parameters \( \mu_0 \) and \( F_C \) are the low-field mobility and the critical field for the onset of non-linearity due to high energy carrier scattering, such as by optic phonons. Both are assumed equal for electrons and holes given the symmetrical band structure of graphene. We also assume \( F_C \) and \( F_{CT} \) may be different as current non-linearity and electronic temperature onset may have different origins; the former is related to the carrier momentum relaxation, whereas the latter is related to the energy relaxation. Neglecting any diffusion processes, and integrating Eq. (2b), we get

\[ I^{\text{drift}}_p - I^{\text{drift}}_n - eW \int_0^L U(x)dx = I. \]

(9)

By using Eq. (7) and the hole current definition,

\[ \frac{C_{ox}W\mu_0(V_{GT} - V)}{1 + \frac{F}{F_C}} + 2eW \int_0^x G(x)dx = I, \]

(10)

where \( I \) is the total current. By integrating Eq. (10) along the channel length \( L \), as usually done in the charge control model (CCM) of conventional MOS device,\(^{17}\) we obtain the expression for the total current in the transistor (see Appendix B)

\[ I = \frac{C_{ox}W\mu_0(V_{GT}V_{DS} - V_{DS}^2/2)}{L \left( 1 + \frac{V_{DS}}{V_C} \right)} + \frac{2eW}{1 + \frac{V_{DS}}{V_C}} \left( 1 - \frac{x'}{L} + \frac{V_{DS} - V(x)}{V_C} \right) G(x')dx', \]

(11)

with \( V_C = F_C L \). Additionally, the expression of the electric field as a function of distance along the channel length\(^{20}\) can be derived from Eq. (10) and is given in Appendix C, where it is shown to be an implicit function of the potential \( V(x) \), and solved by iteration with Eq. (11) for each current \( I \) value.

A. Electric field and potential extrapolation beyond pinch-off

Equations (7), (10) and (11) are obtained under the gradual channel approximation within the CCM that ignores potential and electric field spatial variations beyond the channel pinch-off once current saturation is achieved. As carrier generation by impact ionization mostly occurs in the high field region close to the drain, the distribution of the electric field and potential in that region should be assessed. For this purpose, one can fit \( F \) along the channel given by the actual CCM with a quadratic expression

\[ F(x) = F_0 + ax + bx^2, \]

(12)

where \( F_0 \) is the field at the source and \( a \) and \( b \) coefficients are function of \( V_{DS} \) and \( V_{GT} \) as shown in Fig. 4. Equation (12) is a good approximation on the source side of the transistor, but it underestimates the field on the drain side (see Sec. VI). By integration, one gets the corresponding expression for the electric potential

\[ V(x) = -\left( F_0x + \frac{ax^2}{2} + \frac{bx^3}{3} \right), \]

(13)

with \( V(L) = V_{DS} \) and \( V(0) = 0 \).

One can use self-similarity with expressions (12) and (13) for two channels of different lengths \( L \) and \( L' \), so that
electric potentials and fields are related by the following equations:

\[
V(L; a, b) = V(L'; a', b')
\]

\[
F(L; a, b) = F(L'; a', b'),
\]

yielding

\[
\begin{pmatrix}
    a' \\
    b'
\end{pmatrix} = \frac{6}{L'^3} \begin{pmatrix}
    L' L \left( \frac{L'}{2} - \frac{L'}{3} \right) \\
    L \left( \frac{L'}{2} - \frac{L}{3} \right)
\end{pmatrix} \begin{pmatrix}
    a \\
    b
\end{pmatrix}
\]

\[
+ \frac{6F_0}{L^2} \left( \frac{L - L'}{L' - L} \right).
\]

\]

With this approach, one can then extrapolate the electric field and potential spatial profiles beyond pinch-off by asserting for \( V_{DS}(L') > V_{DSAT}(L') \), \( V_{DS}(L') = V_{DSAT}(L) \) if \( L > L' \) and, similarly, for \( F(L) \) and \( F(L') \). From the field distribution, the carrier concentration along the channel \( n(x) = I/Wev(F(x)) \) is readily obtained by the usual definition of current.

IV. COMPUTATIONAL APPROACH

Because of the interdependence amongst generation rate (G) (Eq. (5)), carrier concentration and potential and electric field profile, we use a self-consistent loop to compute the I-V characteristics of the G-FET (Fig. 5) in this scheme. For each \( V_{DS} \) value, we initialize the loop by computing the current (Eq. (11)) in the absence of carrier generation to obtain the electric field and potential (Eq. (C2)) along the channel, which we then fit with Eqs. (12) and (13) to get the values of \( a \)- and \( b \)-coefficients. We then use Eq. (14) to find \( L' \), and then we re-calculate \( a' \) and \( b' \) beyond pinch-off. From these new sets of values, we compute the initial G-profile, which we use to re-calculate the electric fields (Eq. (14)), carrier concentration and total current (Eq. (11)). The iteration process is repeated until convergence of \( I \) and \( n \).

V. RESULTS

In order to illustrate the effects of carrier multiplication in graphene under high fields, we consider a G-FET with the following parameters: \( W = 2 \mu m, L = 1 \mu m, \mu_0 = 2000 \text{ cm}^2/(\text{Vs}) \),

![Flow-chart of the interaction scheme to calculate the current by taking into account the generation rate self-consistently.](image1)

![Drain current as a function of drain source voltage for several values of \( V_{GT} \): 1 V, 1.5 V, and 2 V (from bottom to up).](image2)

![Electric field as a function of drain source voltage for several values of \( V_{GT} \): 1 V, 1.5 V, and 2 V (from top to down).](image3)
Fig. 7(a) shows the net generation rate along the channel for different drain biases at a fixed gate voltage $V_{GT} = 1$ V, which increases with the drain source voltage, but also shows a quasi exponential increase away from the source as the field and electronic temperature (right axis) increase toward the drain. One notices however a tempering of the generation rate toward the drain at high drain source bias, which is due to the increase in the carrier concentration that limits the rate according to Eq. (5). In Fig. 7(b), we show the effect of the critical field for the onset of electron temperature $F_{CT}$ on the generation rate. As expected, the rate decreases with increasing $F_{CT}$ as the electronic temperature decreases, which weakens the impact ionization process and carrier multiplication. It is the most pronounced on the drain side.

### A. Comparison with experiment

In their seminal 2008 paper, Meric et al.\textsuperscript{13} reported features similar to those shown on Fig. 6 in the I-V characteristics of their double gate G-FET. In order to compare our model with their experimental data, we modify our approach to account for source and drain series resistances, and consider a p-channel. For this purpose, we follow the approach developed by Scott and Leburton,\textsuperscript{20} where the first part of Eq. (11) becomes (for holes)

$$
\frac{C_{ox}W_h[V_{GT}V_{DS} - V_{DS}^2/2]}{L(1 + V_{DS}/V_C)} \rightarrow \frac{V_{DS} - V_C + IR_S + \sqrt{(V_{DS} - V_C + IR_S)^2 - 4IR_SV_{DS}}}{4R_S},
$$

where $I$ is the current in the system and $R_S$ the series resistance. For p-channel, the current is negative, and the sign changes in front of the integral term (Eq. (11)). From Eq. (16), it is clear that there will be a new term in the square root of Eq. (C3), i.e., $[V_{GT} - V_i]^2 - [V_{GT} - V_i - IR_S]^2$. We also add the ohmic drop $IR_S$ from the source in the potential (Eq. (13)).

Fig. 8 compares our model calculations (solid lines) with the experimental data (stars) for two back gate voltages. For both cases, we use the same values of the critical field for onset of velocity non-linearities as in Scott and Leburton.\textsuperscript{20} In Fig. 8(a) ($V_{g\text{back}} = -40$ V), the two current curves for low top gate biases ($V_{g\text{top}} = -0.3$ V and $-0.8$ V) are fitted quite well with $F_{CT} = 22$ kV/cm, for which the effect of carrier generation by impact ionization is weak. For the highest top gate bias ($V_{g\text{top}} = 0$ V), the best fit is obtained with a lower critical field, $F_{CT} = 16$ kV/cm, which is understandable since the hole concentration is smaller, which enhances carrier generation. There is a clear “up-kick” due to the generation rate at high source drain (negative drain) bias in good agreement with the experimental data. Fig. 8(b) displays the comparison between model and experiment for $V_{g\text{back}} = 40$ V and three different top gate biases. We obtain
the field on the drain side compared to the CCM (Fig. 6) we do not believe it alters our conclusions as these discrepancies occur over a short distance, while it is well known that the CCM leads to unphysical large fields on the drain side beyond current saturation.\(^{17}\) Moreover, as mentioned previously, carrier generation itself softens the increase in the field on the drain side, which tends to validate Eq. (12).

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### APPENDIX A

Equation (3) is of the general form
\[
\sum_{k_1, k_2} H(k_1, k_2; k_1', k_2') \delta(k_1 - k_2 - k_1' - k_2') \delta_{k_1+k_2,k_1'+k_2'}
\]
\[(A1)\]
where $H$ is a general function of the wavevectors $k_1, k_{1'}, k_2, k_{2'}$. To evaluate the 8-uple summations, we first exploit one identity of the delta function
\begin{equation}
\delta[(k_1 - k_2)^2 - (k_{1'} + k_{2'})^2] = \frac{\delta(k_1 - k_2 - k_{1'} - k_{2'}) + \delta(k_1 - k_2 + k_{1'} + k_{2'})}{2(k_1 - k_2)},
\end{equation}
where the second term on the right hand side (RHS) is zero since the available phase-space is restricted by energy conservation. We then eliminate the summation over $k_{2'}$ by using the momentum-conservation Kronecker delta,
\begin{equation}
\sum_{k_1, k_{1'}, k_2, k_{2'}} 2H(k_1, k_{1'}; k_2, k_{2'}) \delta[(k_1 - k_2)^2 - k_{1'}^2]
\end{equation}
- $2k_{1'}k_{2'} - (k_1 + k_2 - k_{1'} - k_{2'})^2],
\end{equation}
where $k_{2'} = k_1 + k_2 + k_{1'}$. After expanding the last term in the argument of the $\delta$-function and using momentum conservation, we get
\begin{equation}
\sum_{k_1, k_{1'}, k_2, k_{2'}} H(k_1, k_{1'}; k_2, k_{2'}) \frac{(k_1 - k_2)^2}{2} \delta(k_1k_2\cos^2(\theta_1 - \theta_2/2)
+k_{1'}k_{2'}\sin^2(\theta_1 - \theta_2/2)),
\end{equation}
where $\theta_1, \theta_2, \theta_1', \theta_2'$ are the angles of the respective wavevectors with respect to the field direction (Fig. 10). Now, we transform the sums over the wavevectors $k_{1'}, k_2$ into integrals over their respective magnitudes and angles.
\begin{equation}
\frac{A^2}{(2\pi)^4} \sum_{k_1, k_{1'}} \int \int_0^{2\pi} \int_0^{2\pi} \frac{dk_2dk_{1'}d\theta_{1'}}{2} \delta(k_1k_2\cos^2(\theta_1 - \theta_2/2)
+k_{1'}k_{2'}\sin^2(\theta_1 - \theta_2/2)).
\end{equation}
Let us focus on the double angular integral
\begin{equation}
\frac{2\pi}{2\pi} \int_0^{2\pi} \int_0^{2\pi} H(\theta_1, \theta_2) \delta(k_1k_2\cos^2(\theta_1 - \theta_2/2)
+k_{1'}k_{2'}\sin^2(\theta_1 - \theta_2/2)).
\end{equation}
Here, $H$ is the same function as in Eq. (A1) where the dependence on other variables is omitted for brevity. The $\delta$-function is of the form $\delta(x^2 + y^2)$ with
\begin{equation}
x = \sqrt{k_1k_2\cos(\theta_1 - \theta_2/2)}, \quad y = \sqrt{k_1k_2\sin(\theta_1 - \theta_2/2)}.
\end{equation}
By changing the variables $\theta_1, \theta_2 \rightarrow x, y$, the double angular integral can be transformed into a simpler form
\begin{equation}
\frac{\sqrt{k_1k_2}}{2\pi} \int_{-\infty}^{\infty} \frac{dx}{\frac{\partial x}{\partial \theta_1}} \int_{-\infty}^{\infty} \frac{dy}{\frac{\partial y}{\partial \theta_1}} H(\theta_2(x, \theta_1), \theta_1(\theta_1, \theta_2)) \delta(x^2 + y^2).
\end{equation}
One notes that since the only contribution to the integral occurs at the origin, we can extend the integral limits to the entire $x, y$ plane
\begin{equation}
\frac{\sqrt{k_1k_2}}{2\pi} \int_{-\infty}^{\infty} \frac{dx}{\frac{\partial x}{\partial \theta_1}} \int_{-\infty}^{\infty} \frac{dy}{\frac{\partial y}{\partial \theta_1}} H(\theta_2(x, \theta_1), \theta_1(\theta_1, \theta_2)) \delta(x^2 + y^2).
\end{equation}
and proceed to changing the Cartesian coordinates $x, y$ into the polar coordinates $\rho, \phi$. This yields
\begin{equation}
\frac{\sqrt{k_1k_2}}{2\pi} \int_{0}^{2\pi} \int_{0}^{\infty} H(\theta_2(\rho, \phi), \theta_1(\rho, \phi)) \delta(\rho^2)
\end{equation}
\begin{equation}
= \int_{0}^{2\pi} \int_{0}^{\infty} \frac{d\phi}{\frac{\partial \phi}{\partial \theta_1}} \int_{0}^{\infty} \frac{d\rho}{\frac{\partial \rho}{\partial \theta_1}} H(\theta_2(\rho, \phi), \theta_1(\rho, \phi)) \delta(\rho),
\end{equation}
where we have used the identity $2\rho \delta(\rho^2) = \delta(\rho)$. After carrying out the integrals, we get
\begin{equation}
\pi
2\pi \frac{k_1k_2k_1k_2'}{2\pi} \sin((\theta_1 - \theta_2)/2) \cos((\theta_1 - \theta_2)/2)
\end{equation}
\begin{equation}
= \frac{2\pi}{\sqrt{k_1k_2k_1k_2'}} \sin((\theta_1 - \theta_2)/2) \cos((\theta_1 - \theta_2)/2)
\end{equation}
\begin{equation}
\frac{2\pi}{\sqrt{k_1k_2k_1k_2'}} \sin((\theta_1 - \theta_2)/2) \cos((\theta_1 - \theta_2)/2)
\end{equation}
\begin{equation}
(\theta_1 = 0, \theta_1' = \theta_2').
\end{equation}
It should be noted that $x = 0, \beta = 0$ is equivalent to $\theta_2 = \theta_1 - \pi, \theta_1' = \theta_2'$, respectively. This allows us to write the original expression (A1) as
\begin{equation}
\sum_{k_1, k_{1'}, k_2, k_{2'}} H(k_1, k_{1'}; k_2, k_{2'}) \delta(k_1 - k_2 - k_{1'} - k_{2'}) \delta_{k_1+k_{1'}+k_2+k_{2'}} \frac{A^2}{(2\pi)^4} \int \int_0^{2\pi} \int_0^{2\pi} \frac{dk_1dk_{1'}dk_2dk_{1'}}{2\pi} \int \int_0^{2\pi} \int_0^{2\pi} \frac{d\theta_1d\theta_{1'}d\theta_2d\theta_{1'}}{2\pi} \frac{1}{\sqrt{k_1k_2k_1k_2'}} \sin((\theta_1 - \theta_2)/2) \cos((\theta_1 - \theta_2)/2).
which reduces our six-fold summation over \( k_1', k_2, k_2' \) into a two-dimensional integral over \( k_2, k_1' \) and finally write

\[
\frac{A^2}{16\pi^3} \sum_{k_1} \int_0^\infty dk_1' \int_0^\infty dk_2 k_2 \\
\times \frac{(k_1 - k_2)}{\sqrt{k_1 k_2 k_1' k_2'}} H(k_1 k_2' k_1 k_2) |_{k_1 = k_1' + k_2 - k_2'} \theta_1 = \theta_2 + \pi, \theta_3 = \theta_3',
\]

(A13)

where \( \theta_2' \) represents the angle of the vector \( k_1 + k_2 - k_1' \) all being co-linear.

The expression (A13), which is different from Eq. (14) in Ref. 21 is equivalent to Eq. (8) in Ref. 12, except for a factor \( 1/2 \), which is readily corrected.

**APPENDIX B**

Equation (11) is obtained as follows:

After multiplying both sides of Eq. (10) by \( 1 + F/F_C \) and integrating from source to the x-position in the channel,\(^{17}\) one gets

\[
\left( 1 + \frac{V(x)}{F_C} \right) \frac{I}{W} = C_{oa}\mu_0 [V_{GT} - V(x)/2] V(x)
\]

\[+ 2e \int_0^x \left( 1 + \frac{F}{F_C} \right) dx' \int_0^{x'} G(x'')dx''. \quad \text{(B1)}\]

The double integral in the last term of Eq. (B1) can be integrated by parts, yielding

\[
\int_0^x \left( 1 + \frac{F}{F_C} \right) dx' \int_0^{x'} G(x'')dx'' = \int_0^x G(x')dx' \int_0^x \left( 1 + \frac{F}{F_C} \right) dx''
\]

\[= \left( x + \frac{V(x)}{F_C} \right) \int_0^x G(x')dx' - \int_0^x G(x') \left( x' + \frac{V(x')}{F_C} \right) dx'. \quad \text{(B2)}\]

After taking the limit \( x > L \) and rearranging Eqs. (B1) and (B2) one obtains Eq. (11).

**APPENDIX C**

Equation (12) for the electric field along the channel is obtained by combining Eqs. (B1) and (B2), which yields

\[
\left( 1 + \frac{V}{F_C} \right) \frac{I}{W} = C_{oa}\mu_0 [V_{GT} - V/2] V
\]

\[+ 2e \left( x + \frac{V}{F_C} \right) \int_0^x G(x')dx' - 2e \int_0^x G(x') \left( x' + \frac{V(x')}{F_C} \right) dx', \quad \text{(C1)}\]

from which one obtains an implicit expression for the potential along the channel by solving the second order algebraic equation in \( V \)

\[
V(x) = \begin{cases} 
V_{GT} - V_i + \frac{2e}{F_CC_{oa}\mu_0} \int_0^x G(x')dx' & \text{if } x > x_i, \\
\left[ V_{GT} - V_i + \frac{2e}{F_CC_{oa}\mu_0} \int_0^x G(x')dx' \right]^2 - 2F_CV_i x + \frac{4e}{C_{oa}\mu_0} \int_0^x \left[ x - x' + \frac{V(x)}{F_C} \right] G(x')dx' & \text{if } x < x_i, \end{cases}
\]

(C2)

where \( V_i = \frac{I}{W_0 FC_{oa}} \).

Deriving Eq. (C2) with respect to position \( x \) yields the electric field
\[
F(x) = -\left\{ \frac{2eG(x)}{FC_{\text{ox}}h_0} \left[ V_{\text{GT}} - V_i - V(x) + \frac{2e}{FC_{\text{ox}}h_0} \int_0^x G(x') dx' \right] + \frac{2E}{C_{\text{ox}}h_0} \int_0^x G(x') dx' - FC_{\text{ox}}V_i \right\}^{1/2} \left[ V_{\text{GT}} - V_i + \frac{2e}{FC_{\text{ox}}h_0} \int_0^x G(x') dx' \right]^{1/2} - 2FC_{\text{ox}}V_i x + \frac{4e}{C_{\text{ox}}h_0} \int_0^x x - x' + \frac{V(x)}{F_C} G(x') dx' \right\}.
\]

(C3)